

## **Safety Documentation**

Please select the forms you require by selecting the check boxes below.

You can select more than one.

Process Risk Assessment

Method Statement

Chemicals COSHH

Once you have made your selections, scroll down and complete the forms.

Buttons: [+] will add a row to a list

You may save this file to a local drive at any time.

When you have finished, save the file to a local drive and email it to your supervisor for authorisation.

**Supervisors** - There is a sign-off section at the end of the document set that must be completed.

Staff may "self authorise", (as a supervisor), but the forms must still be submitted to the DSO for approval.

#### **IMPORTANT:**

YOU <u>MUST NOT</u> START ANY PRACTICAL WORK UNTIL THESE FORMS HAVE BEEN RETURNED TO YOU WITH **BOTH** YOUR SUPERVISOR'S AND DSO'S APPROVAL SIGNATURES ATTACHED.

Please complete these fields				
Department	Wolfson School of Mechanical, Electrical & Manufacturing Engineering			
Name	Ignacio Martin-Fabiani			
email address	i.martin-fabiani@lboro.ac.uk			
Location	T208b			
Project / Activit	y / Task Atomic Force Microscopy of polymer and nanocomposite films			

Version: 2.09



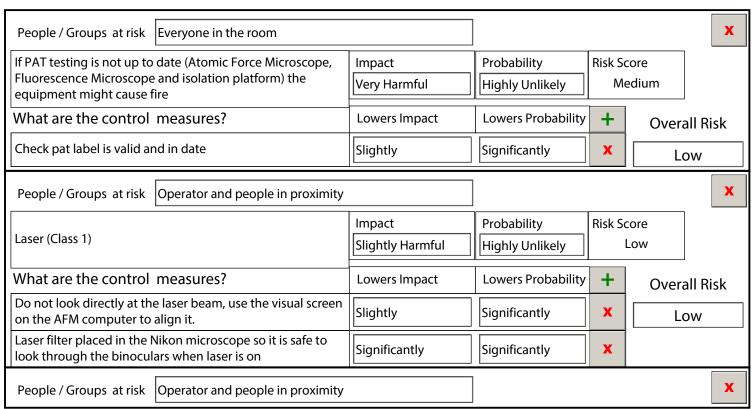
### **Process Risk Assessment**

10003511131171350551110110		Reference CBE 118		
Location	T208b	Originator	Ignacio Martin-Fabiani	
Project / Activity / Task	Atomic Force Microscopy of polymer and nanocomposite films			

#### What are the hazards associated with this process?

Category 1: Machinery & work equipment:						
Design and Construction Mechanical hazards Electrical hazards Radiation hazards						
N/A	N/A   N/A   Electrical test labels current   Lasers					
Category 2: Workplace				+		
Other workplace hazards - Bioh	nazards			X		
Category 3: Hazardous and	d/or Harmful substances			+		
N/A				X		
Category 4: Work activity				+		
N/A						
Category 5: Work organisation						
N/A						

#### What are the risks associated with these hazards?



## Process Risk Assessment Form (Continued)

Presence of biohazards in the lab	Impact Very Harmful	Probability Highly Unlikely	Risk So	core edium
What are the control measures?	Lowers Impact	Lowers Probability	+	Overall Risk
Wear PPE (gloves, lab coat, googles)	Moderately	Significantly	X	Low
Do not get close to biosafety cabinets	Slightly	Significantly	X	
+ Add another Risk				

#### Who may be at risk as a result of this activity?

Personnel Group	Maximum (Task setup/ Re- configuration)	High (Performing the task)	Medium (Observing the task)	Low (Present, but not involved)	Lone Working (Out of hours)	No Exposure Permitted	Total
Academic Staff	1	0	0	0	0	0	1
Technical Staff	0	0	0	1	0	0	1
Research Staff (PDRA)	0	0	0	0	0	0	0
Research Students (PhD)	0	1	0	0	0	0	1
Students (Undergraduate / MSc)	0	0	0	0	0	0	0
Visitors	0	0	0	0	0	0	0
Others - Over-type as needed	0	0	0	0	0	0	0
Total	1	1	0	1	0	0	3

With these controls in place, the risk is:

## The activity is LOW RISK - and is effectively controlled

		LASER DETAILS			
Class	Class 1	Туре	CW	Wavelength (nm)	980
System Classification	Class 1	Laser Illumination	Point Source		
Beam Delivery	Open Beam				

## Process Risk Assessment Form (Continued)

Metals		letals		
☐ Drilling	☐ Cutting	☐ Drilling		
Surface Treatment	☐ Welding	Surface Treatment		
Other		Other - AFM imaging		
Research				
✓ Illumination				
	☐ Drilling ☐ Surface Treatment ☐ Research	□ Drilling □ Cutting   □ Surface Treatment □ Welding   Other - AFM imaging     □ Research		



Reference CBF118

## Safety Method Statement

		Herere	100
Location	T208b	Originator	o Martin-Fabiani
Project / Activity / Task	Atomic Force Microscopy of polymer and nanocomposi	te films	
What equipment will	I be used in this activity?		+
JPK Atomic Force Micros	scope, Nikon Fluorescence Microscope, Isolation Platforn	1	X
What training must b	pe completed to do this activity?		+
AFM and Fluorescence n	nicroscope (both already completed)		X
What chemicals are b	peing used? (These must be included in the CC	SHH Form)	+
None			X
Spill and accident pro	ocedures.		+
N/A			X
Procedure in the eve	ent of an emergency. (How to leave the process in a	safe condition in such	an event)
Turn off all equipment a	nd leave. Alert a technician.		X
References.			+
JPK Nanowizard User Ma	anual		X

## Detailed sequential description of the process

Process step	Precautionary measures and comments	+
No sample preparation required. Samples (polymer dry films on cover slips will be prepared in the Materials department and brought to the Wolfson lab ready for measuring.  Please refer to the SOP of the JPK Nanowizard for AFM imaging procedure.		x



## Supervisor and Departmental Safety Office (DSO) Sign-off.

#### **Supervisors**

Please check the documents above and if you want to approve them:

- 1) Electronially sign this document
- 2) Save it to a local drive (You will be prompted to do this)
- 3) eMail the signed document to the DSO.

#### **DSO**

Please review the documents above and if you want to approve them:

- 1) Enter the reference numbers as appropriate
- 2) Electronically sign this document
- 3) Save it to a local drive (You will be prompted to do this)
- 3) eMail the signed document to the originator

#### This document set must be reviewed and re-approved at the following times:

- 1) After the first occurrence of the activity described above (Review only)
- 2) After any change to the procedure or reagents used
- 3) After any incident resulting from this activity
- 4) At least annually from the date of approval

lext		

06/07/2018

**Review comments** 

Although the user is viewing pre-prepaird samples (dry polymer films) T.2.08b is a biological class .two containment area and as such aseptic tectonics must be flowed.

Air conditioning which is important for the stability of other equipment in the lab must be left on. As with other equipment in the lab must not be turned off fridges, freezers, incubators, BSC's ect this is a working lab.

Also there was an agreed footprint for the equipment if it has strayed outside that footprint and the space is required for other work expect items to be moved back into the agreed space.